

Original Paper

Molten Metal Flux Growth and Study of Properties and Chemical State of a New Compound $\text{PrRh}_{4.8}\text{B}_2$

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The hexagonal plate-like single crystals of a new compound $\text{PrRh}_{4.8}\text{B}_2$ were obtained by a molten metal flux growth method using Cu as a flux. $\text{PrRh}_{4.8}\text{B}_2$ is orthorhombic with the space group $Fmmm$; $a = 0.9697(4)$, $b = 0.5577(2)$ and $c = 2.564(3)$ nm. The structure of the compound is of a modified CeCo_3B_2 -type which is explained by a stacking model of Pr-B and rhodium layers. The temperature dependence of inverse static magnetic susceptibility, χ^{-1} obeys the Curie-Weiss law at temperatures above 50 K. The μ_{eff} is $4.2 \mu_B$ and Θ_p is -13 K. The susceptibility deviates from the Curie-Weiss law below 50 K, suggesting some magnetic ordering. The value of micro-Vickers hardness for c -plane with the orthorhombic symmetry of $\text{PrRh}_{4.8}\text{B}_2$ is 6.7 ± 0.6 GPa. The TG curve shows that oxidation of the $\text{PrRh}_{4.8}\text{B}_2$ proceeds above 873 K. Weight gain of the specimen heated up to 1473 K in air is 13 %. After TG-DTA measurement, final product is PrBO_3 and Rh. The X-ray photoelectron spectroscopic study and electron probe micro-analysis results show that a few monolayers of Cu atoms exist between the crystals of $\text{PrRh}_{4.8}\text{B}_2$.

Key Words: $\text{PrRh}_{4.8}\text{B}_2$, Flux Growth, Crystal Structure, Magnetic Property, Hardness, TG-DTA, X-ray Photoelectron Spectrum

1. Introduction

The crystal chemistry of R-Rh-B (R = rare earth element) systems has received considerable attention from many researchers in the fields of crystallography, magnetism, superconductivity, heavy-electron behaviour, valence fluctuations and catalytic properties[1-8]. The earlier paper provided the existence of six binary compounds, Pr_3Rh , Pr_7Rh_3 , Pr_5Rh_3 , Pr_5Rh_4 , PrRh_2 , and PrRh_3 for the Pr-Rh system[9]. Moreover, three compounds, Pr_2B_5 , PrB_4 and PrB_6 [10], and two compounds, Rh_7B_3 and RhB [11,12] were reported for Pr-B and for Rh-B systems, respectively. On the other hand, only two compounds, PrRh_3B [13] and PrRh_3B_2 [14] were reported in the ternary Pr-Rh-B system. In this paper we report on the title compound, $\text{PrRh}_{4.8}\text{B}_2$ which is newly obtained by the molten metal flux growth method using Cu as flux. Growth, crystallographic data, magnetic properties, hardness, oxidation resistivity, and chemical state of the compound are presented.

2. Experimental details

2.1 Crystal growth

The starting materials used were small pieces of 99.9 % Pr, 99.9 % Rh powder and 99.9 % B powder. They were weighed in several atomic ratios of Pr, Rh and B, and mixed with 99.999 % of Cu powder in a weight ratio 1:10 for (Pr+Rh+B):Cu. The mixture

of the four elements was placed in a high purity (99.9 %) dense alumina crucible, which was inserted in a vertical electric furnace. Ar was flowing at a rate of $200 \text{ mL} \cdot \text{min}^{-1}$ in the furnace as a protecting atmosphere against oxidation. Then the mixture of the starting materials was heated at a rate of $673 \text{ K} \cdot \text{h}^{-1}$ up to 1673 K, and kept at that temperature for 10 h, and then slowly cooled down at a rate of $10 \text{ K} \cdot \text{h}^{-1}$ to 1353 K. Temperature was controlled at the bottom of the crucible during all heating and cooling processes. At 1673 K, the soaking temperature of the solution, the height of the melt was about 30 mm and the temperature at the melt surface and the bottom was 1643 K and 1673 K, respectively. After the temperature reached 1353 K, the furnace was rapidly cooled down to room temperature. The grown crystals were separated by dissolving Cu in diluted nitric acid.

2.2 Characterization

The surface of the crystals was analyzed by scanning electron microscope (SEM). The chemical analysis was carried out using the inductively coupled plasma (ICP) technique after fusion of the samples with NH_4HSO_4 . The X-ray analyses were performed using a Burger precision camera with zirconium-filtered $\text{MoK}\alpha$ radiation and a four-circle X-ray diffractometer with graphite-monochromatized $\text{MoK}\alpha$ radiation. The magnetic properties were determined with a pendulum-type magnetometer in the temperature range of 1.8 to 300 K. Micro-Vickers hardness (MVH) of the as-

grown single crystals was measured at room temperature. A load of 100 g was applied for 15 s and ten impressions were recorded for each individual face of the crystal. The obtained values were averaged and the experimental error was estimated. Thermo-gravimetric (TG) analysis and differential thermal analysis (DTA) were performed between room temperature and 1473 K to study the oxidation resistivity of the crystals in air. A sample of about 25 mg was heated at a rate of $10 \text{ K}\cdot\text{min}^{-1}$ up to 1473 K. The oxidation products were analyzed by powder X-ray diffractometry. Initial oxidation behavior of the specimen was examined by X-ray photoelectron spectroscopy (XPS). The XPS spectra were taken from the following two conditions: (i) clean surfaces coated with no oxide layer prepared by fracturing the specimen in an ultra high vacuum and (ii) surface oxidized by exposing the fractured surface to high purity oxygen at a pressure of $1.3 \times 10^{-6} \text{ Pa}$.

3. Results and Discussion

3.1 Morphology and crystal structure of the single crystals

Single crystals in the form of a hexagonal plate and powder like crystals were extracted at the starting composition $\text{Pr:Rh:B} = 1:3:1$. In this paper, we focus our attention on the hexagonal plate-like single crystals. They have silver metallic luster and the mean size of the crystals is approximately $5 \text{ mm (width)} \times 0.5 \text{ mm (thickness)}$. The chemical analysis of the plate-like crystals indicates that the chemical formula of the compound is $\text{PrRh}_{4.8}\text{B}_2$. Figure 1(a) shows a SEM image of a hexagonal plate-like single crystal. Figure 1(b) is

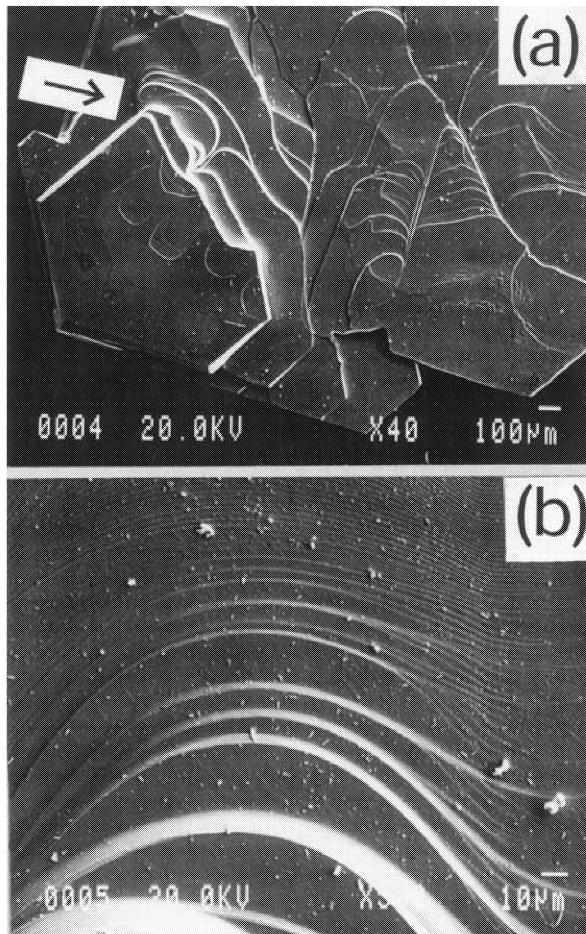


Fig.1 SEM image of a hexagonal plate-like single crystal of $\text{PrRh}_{4.8}\text{B}_2$.

an enlargement of the corresponding region indicated by an arrow in (a) and it reveals the terrace growth. The phase diagram of the Pr-Rh-B system is shown in Fig.2. Six binary intermetallic compounds, Pr_3Rh , Pr_7Rh_3 , Pr_5Rh_3 , Pr_5Rh_4 , PrRh_2 , and PrRh_3 exist in the Pr-Rh system. Three compounds, Pr_2B_5 , PrB_4 , and PrB_6 also exist in the Pr-B system while Rh-B system involves two compounds, Rh_7B_3 and RhB . The authors have reported the formation of PrRh_3B in the Pr-Rh-B ternary system[13]. This compound is perovskite-type boride and it has cubic symmetry (space group; $Pm\bar{3}m$). Ternary boride PrRh_3B_2 has been reported by Ku *et al.*[14]. It has a hexagonal CeCo_3B_2 -type structure which can be derived from the CaCu_5 -type structure with the $P6/mmm$ space group. The compositional position of a new compound $\text{PrRh}_{4.8}\text{B}_2$ is shown in Fig.2. As a result, PrRh_3B , PrRh_3B_2 and a new compound $\text{PrRh}_{4.8}\text{B}_2$ exist in the rhodium-rich portions of the Pr-Rh-B ternary phase diagram.

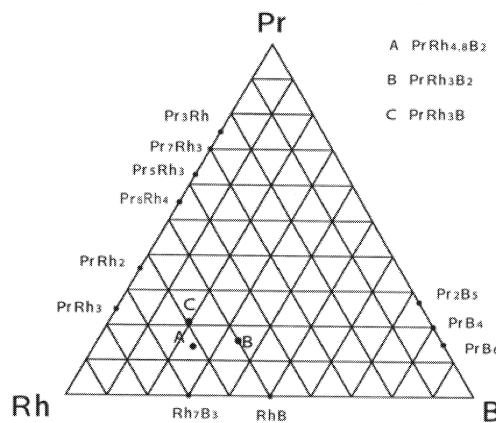


Fig.2 Compositional position of the new compound $\text{PrRh}_{4.8}\text{B}_2$ on the phase diagram of Pr-Rh-B . Previously reported compounds PrRh_3B and PrRh_3B_2 are also shown in the figure.

The X-ray structure analysis of the single crystal reveals that the compound is orthorhombic with a space group $Fmmmm$ and the lattice parameters are $a = 0.9697(4)$, $b = 0.5577(2)$, and $c = 2.564(3) \text{ nm}$, respectively[8]. The basic crystal data are presented in Table 1. The arrangement of the atoms in the crystal is shown in Fig. 3 with (a) showing the perspective drawing of the full structure

Table 1 Crystallographic data of $\text{PrRh}_{4.8}\text{B}_2$.

Chemical formula	$\text{PrRh}_{4.8}\text{B}_2^{\text{a}}$
Crystal system	Orthorhombic
Structure type	Modified- CeCo_3B_2
Space group	$Fmmmm$
Lattice parameter (nm)	
a	0.9697(4)
b	0.5577(2)
c	2.564(3)
Formula units per unit cell	12

^aFormula unit determined by the chemical and structural analyses.

of $\text{PrRh}_{4.8}\text{B}_2$ and (b), the Kagome (3636) nets of rhodium atoms ($z = \pm 0.2$) as seen along the c -axis. The structure of this compound is a modified CeCo_3B_2 -type and it is made up of PrRh_3B_2 -block and ‘partly-occupied Rh layer’, parallel to the (001) plane. The PrRh_3B_2 -block consists of two different infinite layers: one of them is a Pr-B layer and the other, a Rh layer. The chemical formula of this compound as obtained from X-ray analysis is $\text{PrRh}_{4.8}\text{B}_2$ and it is in agreement with the chemical analysis described above.

3.2 Magnetic properties

The temperature dependence of the inverse static magnetic susceptibility, χ^{-1} and the magnetization curves at 4.7 K and room temperature are shown in Fig.4 and Fig.5, respectively. The inverse susceptibility deviates from the Curie-Weiss law below 50 K and the magnetization curve at 4.7 K has a small weak ferromagnetic component, suggesting some magnetic ordering. In all the cases the magnetic field is applied in the thin c -plane. The effective magnetic moment of the Pr ion and the Curie-Weiss temperature were determined from the slope and the intercept of the straight line with the T-axis, respectively. The μ_{eff} is $4.2 \mu_B$ and Θ_P is -13 K . The value of the effective magnetic moment is larger than the theoretical Hund’s value of $3.6 \mu_B$ for the free trivalent ion Pr^{3+} .

3.3 Hardness [15]

As presented in Table 2, the value of MVH for c -plane of the orthorhombic symmetry of $\text{PrRh}_{4.8}\text{B}_2$ is $6.7 \pm 0.6 \text{ GPa}$. The data for PrRh_3B , PrRh_3B_2 , Rh_3B and Rh_7B_3 are also listed in the table. Samsonov and Vinitskii pointed out that the hardness of the binary borides increases with boron content in the system of Rh and B[15,16]. This tendency of the binary borides is also found in the ternary borides that are composed of Pr, Rh and B elements. Considering the lower boron content in ternaries, the hardness of PrRh_3B_2 is relatively high. This result suggests that the hardness of the boride depends on not only boron content in the compound but also on other factors, for example, the crystal structure of each compound.

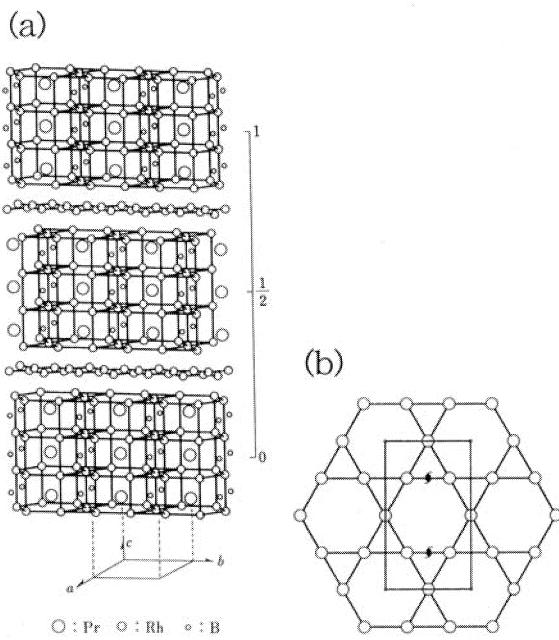


Fig.3 (a) Perspective drawing of the full structure of $\text{PrRh}_{4.8}\text{B}_2$ and (b) the Kagome (3636) nets of rhodium atoms ($z = \pm 0.2$) as seen along the c -axis[8].

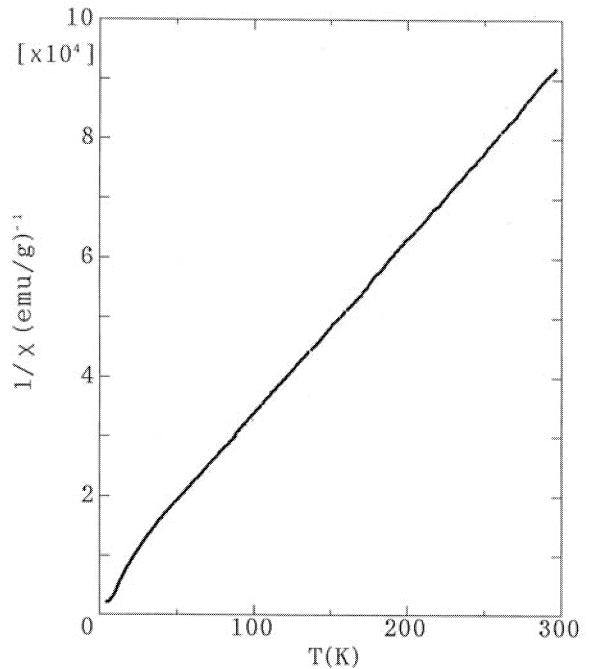


Fig.4 The temperature dependence of the inverse static magnetic susceptibility, χ^{-1} of $\text{PrRh}_{4.8}\text{B}_2$.

3.4 TG-DTA

The TG-DTA curves for $\text{PrRh}_{4.8}\text{B}_2$ in air are shown in Fig.6 as solid lines. The data for PrRh_3B and PrRh_3B_2 measured under the same conditions are also shown in the figure as references. The TG curve shows that the oxidation of $\text{PrRh}_{4.8}\text{B}_2$ proceeds above 873 K. Above 1273 K weight loss may correspond to the evaporation of boron oxide. Weight gain of the specimen heated up to 1473 K in

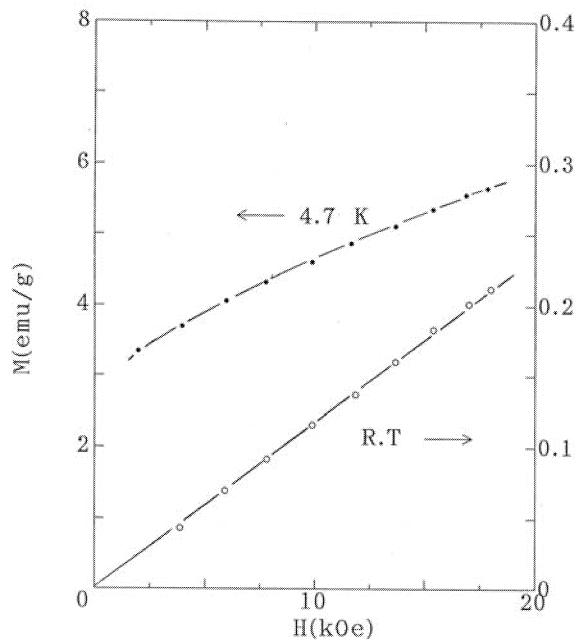


Fig.5 The magnetization curves at 4.7 K and room temperature.

Table 2 Vickers microhardness of the $\text{PrRh}_{4.8}\text{B}_2$ and related compounds that exist in the Pr-Rh-B ternary system.

Compound	Boron content (atom%)	Crystal structure	Microhardness (Hv, GPa)	References
$\text{PrRh}_{4.8}\text{B}_2^{\text{a}}$	25.6	Orthorhombic	6.7 ± 0.6	This study
$\text{PrRh}_3\text{B}^{\text{b}}$	20.0	Cubic	8.2 ± 0.1	[15]
$\text{PrRh}_3\text{B}_2^{\text{b}}$	33.3	Hexagonal	10.5 ± 0.3	[15]
RhB^{c}	50.0	Hexagonal	12.13	[16]
$\text{Rh}_2\text{B}_3^{\text{c}}$	30.0	Hexagonal	7.77	[16]

Values for the compounds belonging to Rh-B binary system are also given.

^aSingle crystal.

^bPoly crystal.

^cNot shown single crystal or polycrystal.

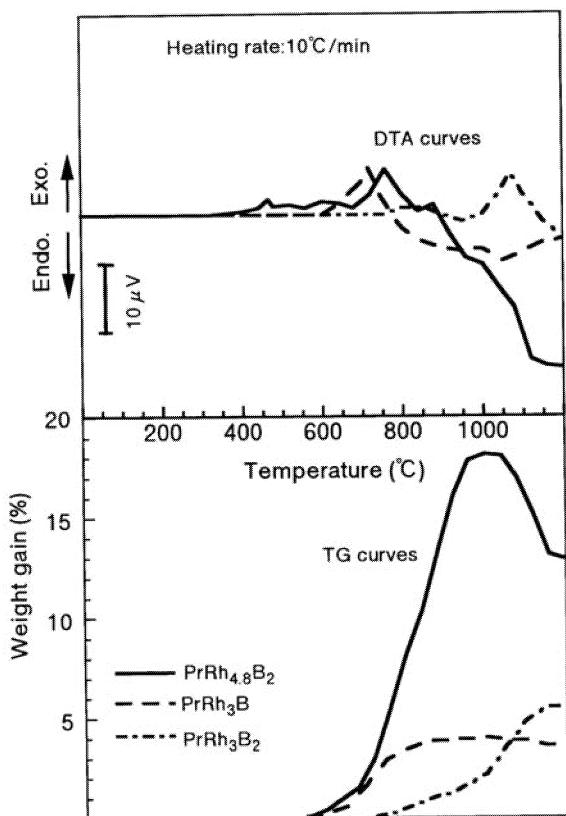


Fig.6 TG-DTA curves (solid lines) for $\text{PrRh}_{4.8}\text{B}_2$. Data for PrRh_3B and PrRh_3B_2 are presented as references.

air is 13 %. In the DTA curve, the exothermic peaks caused by oxidation are found at 753 K, 1033 K and 1153 K, respectively. Above 1173 K, DTA curve largely deviates from straight line to endothermic site. This phenomenon is ascribable to the evaporation of boron oxide. The final products, obtained by heating up to 1473 K, were PrBO_3 (orthorhombic symmetry) and Rh (cubic symmetry). Phenomenal temperature and weight gain from TG-DTA measurement for $\text{PrRh}_{4.8}\text{B}_2$ are summarized in Table 3.

Basically, resistance to oxidation of a compound relates to its crystal structure[6]. As mentioned above, the structure of $\text{PrRh}_{4.8}\text{B}_2$ can be described by sheets of modified CeCo_3B_2 -type structure stacked along the *c*-direction. $\text{PrRh}_{4.8}\text{B}_2$ single crystals display

Table 3 Phenomenal temperature, weight gain and final product from the TG-DTA measurement in air for $\text{PrRh}_{4.8}\text{B}_2$.

Sample	Oxidation proceeded by TGA (°C)	Exothermal maximum by DTA (°C)	Weight gain by TGA (%)	Final products
$\text{PrRh}_{4.8}\text{B}_2$	> 600	480, 760, 880	13	PrBO_3 and Rh

extremely plastic character and they are easy to cleave parallel to the (001) plane. This fact suggests that the weak bonding occurs between the sheets through the ‘partly-occupied rhodium sheets’. It is well known that the layer structure compounds, for example, CaZn_5 -type[17-21] and $\text{Th}_2\text{Ni}_{17}$ -type[22], exhibit high affinity for H_2 , N_2 , etc. Poor oxidation resistance of $\text{PrRh}_{4.8}\text{B}_2$ can be explained by its characteristic layer structure, especially the existence of ‘partly-occupied rhodium sheets’. On the other hand, reference sample of PrRh_3B represents high oxidation resistance (Fig.6). Crystal structure of PrRh_3B is cubic (space group; $Pm\bar{3}m$)[13] and therefore it behaves as isotropic with regard to oxidation and it shows high resistance to oxidation. PrRh_3B_2 has hexagonal symmetry with CeCo_3B_2 -type (space group; $P6/mmm$) structure[14] and its resistance to oxidation is medium among the three ternary borides (Fig. 6). As a result, the oxidation resistivity of $\text{PrRh}_{4.8}\text{B}_2$ is low. However, the authors have a strong interest in the affinity of this compound for H_2 from the viewpoint of hydride-forming intermetallic compounds, because this compound is one of the variations of the CaZn_5 -type structure. The determination of the H_2 sorption in $\text{PrRh}_{4.8}\text{B}_2$ is currently under way.

3.5 Chemical state

SEM images taken from EPMA of the fractured surface and $\text{PrL}\alpha$, $\text{RhL}\alpha$, $\text{CuK}\alpha$ X-ray images are shown in Fig.7. It is found that Pr and Rh are uniformly distributed throughout the specimen, but that Cu is in-homogeneously distributed. Because measurements are carried out with a spot size of $300 \mu\text{m}$ in the XPS analysis, the images represent two-dimensionally averaged composition. Figure 8 shows XPS survey spectrum for the fractured $\text{PrRh}_{4.8}\text{B}_2$ surface. XPS survey spectrum for the surface layers yields photoelectron peaks belonging to nominal elements of Pr, Rh and B. Furthermore, Cu Auger peaks are observed at ca. 570 eV, indicating that Pr 3d and Cu 2p peaks are overlapping. It was difficult to estimate the relative concentrations of the elements due to the overlap of the major photoelectron peaks. Initial oxidation behavior of the specimen was examined by the comparison of the as-fractured spectrum with the oxidized spectrum, as shown in Fig.9, Fig.10, and Fig.11. In the Pr 3d and Cu 2p regions for the as-fractured specimens, two peaks corresponding to spin-orbit splitting are observed (Fig.9(a)). The binding energy for the lower energy peak is 932.0 eV which is 0.2 eV higher than that of $\text{Pr 3d}_{5/2}$ peak for elemental Pr and 0.7 eV lower than that of $\text{Cu 2p}_{3/2}$ for elemental Cu[23]. The result would be due to the overlap between Pr 3d and Cu 2p peaks. After exposing to low-pressure oxygen atmosphere, two new peaks appear at 932.9 eV and 929.0 eV (Fig.9(b)). These peaks correspond to those of Pr_2O_3 and satellite peak associated with Pr_2O_3 , respectively[24], indicating that one of the initial oxides formed on $\text{PrRh}_{4.8}\text{B}_2$ is Pr_2O_3 . In the spectrum as shown in Fig.10, in Rh region no significant difference is observed between the as-fractured and the oxygen-exposed surfaces, indicating that Rh is not oxidized in the low-pressure oxygen atmosphere. The binding energy of B 1s peak for the as-fractured surface is 188.3 eV (Fig. 11(a)), which is lower than that of elemental B[23]. This trend is similar to the HoRh_3B case[25]. After the exposure to oxygen, new peak appears at 191.7 eV (Fig.11(b)), the value of which agrees with boron-oxide. Similar to

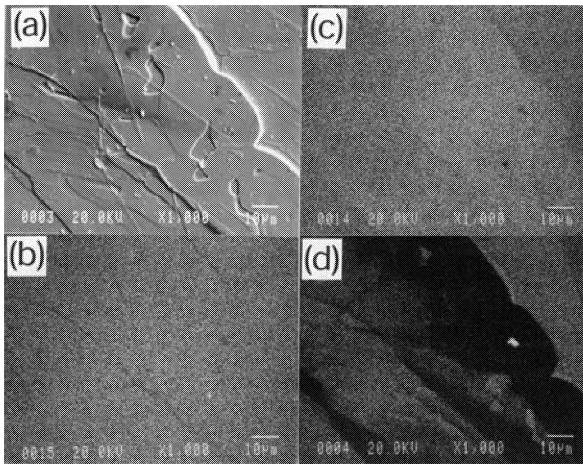


Fig.7 (a) SEM image of the fractured surface of the crystal. (b) Pr $K\alpha$, (c) Rh $K\alpha$, and (d) Cu $K\alpha$ X-ray images are also shown.

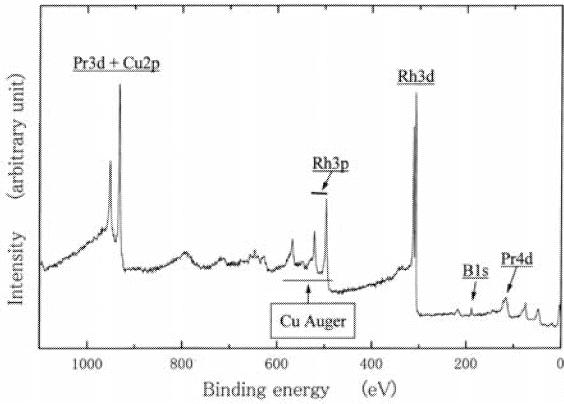


Fig.8 Wide range XPS spectrum of PrRh_{4.8}B₂ fractured in the spectrometer.

the initial oxidation behavior of hafnium hydride[26], the oxidation of Pr and B on PrRh_{4.8}B₂ proceeded very rapidly, whereas the oxide of Rh is not observed after the oxygen-exposure. The result indicates that oxidations of Pr and B occurred prior to that of Rh.

Even in case where the specimen was fractured in air, B 1s peak which is ascribed to the compounds was observed. This means that kinetic energy of B 1s photoelectron is larger than that of Pr 3d and that B 1s spectra have more profound information from deeper layer than B 3d spectra do. According to EPMA, ratio of Cu/Pr in the specimen is in the range of 0.20 and 1.53[8]. However, in the analysis of crystal structure by means of XRD, the reliability factor for the case where Cu is assumed to be involved in the specimen is worse than that for the case where Cu is assumed to be absent and also no peak was observed in XRD at all. From these facts and also from the change of XPS spectrum, it can be concluded that Cu atoms exist sporadically between the crystals of PrRh_{4.8}B₂, forming domains as thick as a few atomic layers.

4. Conclusions

The authors can draw the following conclusions from this study.

- (1) A new compound PrRh_{4.8}B₂ with silver metallic luster is successfully grown in the form of hexagonal plates ($\sim 5 \times 0.5 \times 0.5$ mm³) by solution growth method using Cu as flux. Cu

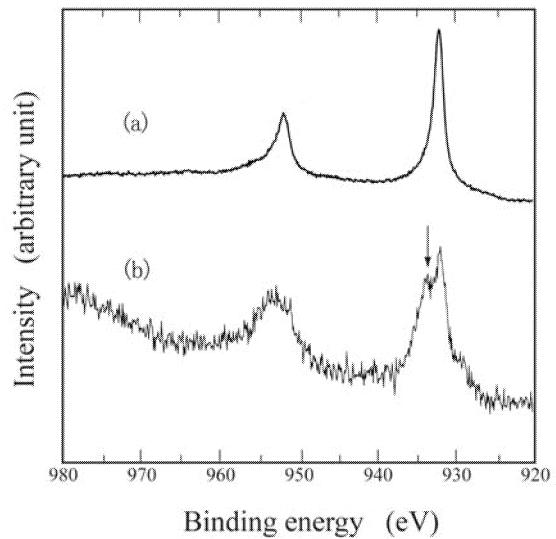


Fig.9 Pr 3d and Cu 2p XPS spectra for the two states of the sample, (a) fractured in the spectrometer and (b) exposed to oxygen for 300 s after (a).

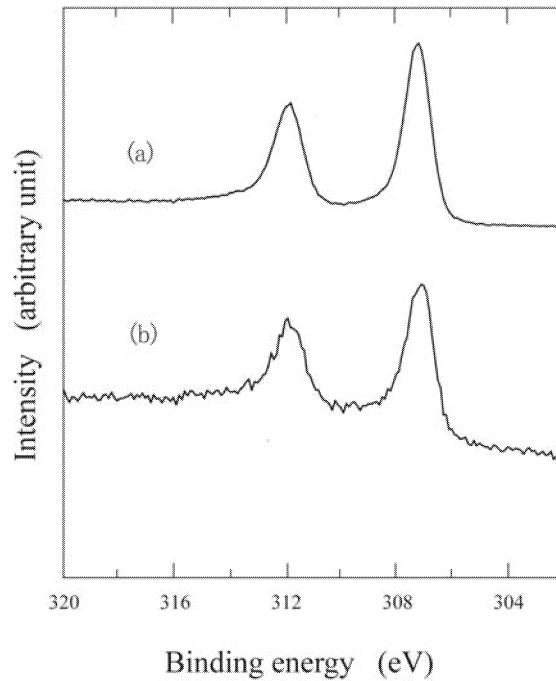


Fig.10 Rh 3d XPS spectra for the two states of the sample, (a) fractured in the spectrometer and (b) exposed to oxygen for 300 s after (a).

acted as a good intermediate[27-30] for the crystal growth of this new ternary boride.

- (2) PrRh_{4.8}B₂ belongs to an orthorhombic system with the space group Fmm . The lattice parameters are $a = 0.9697(4)$, $b = 0.5577(2)$ and $c = 2.564(3)$ nm, respectively. The structure of the compound is a modified CeCo₅B₂ type which is explained by a stacking model of Pr-B and rhodium layers.

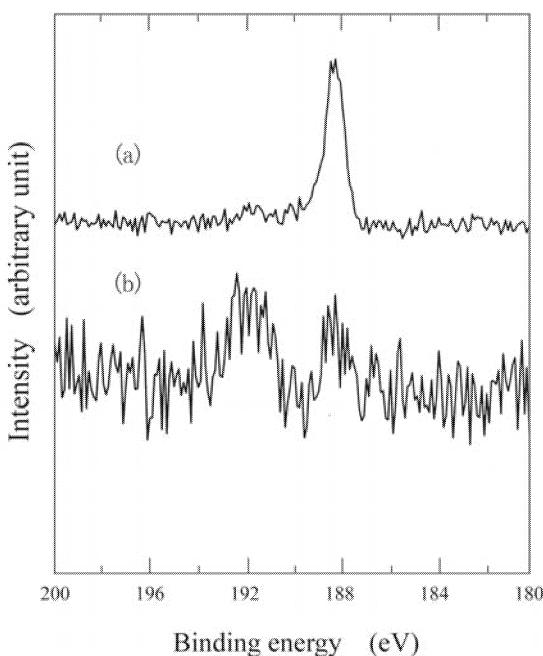


Fig.11 B 1s XPS spectra for the two states of the sample, (a) fractured in the spectrometer and (b) exposed to oxygen for 300 s after (a).

- (3) The temperature dependence of inverse static magnetic susceptibility, χ^{-1} obeys the Curie-Weiss law at higher temperature above 50 K. The μ_{eff} is $4.2 \mu_B$ (Hund's value for Pr^{3+} : $3.6 \mu_B$) and Θ_p is -13 K. The susceptibility deviates from the Curie-Weiss law, below 50 K, suggesting some magnetic ordering.
- (4) The value of MVH for *c*-plane with the orthorhombic symmetry of $\text{PrRh}_{4.8}\text{B}_2$ is 6.7 ± 0.6 GPa.
- (5) The TG curve represents that oxidation of $\text{PrRh}_{4.8}\text{B}_2$ proceeds above 873 K. Weight gain of the specimen heated up to 1473 K in air is 13 %. After oxidation measurement, final product is PrBO_3 (orthorhombic symmetry) and Rh (cubic symmetry).
- (6) The X-ray photoelectron spectroscopic study and electron probe micro-analysis results show that a few monolayers of Cu atoms exist between the crystals of $\text{PrRh}_{4.8}\text{B}_2$.

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